# The role of the singlet metastables in capacitively coupled oxygen discharges

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#### **Introduction**

- Oxygen is a weakly electronegative gas and the presence of negative ions has a strong influence on the kinetics and dynamics of the oxygen discharge
- The oxygen discharge is of vital importance in various materials processing applications such as
  - ashing of photoresist
  - etching of polymer films
  - oxidation and deposition of thin film oxides
- The oxygen chemistry is rather involved, in particular due to the presence of metastable molecular and atomic oxygen and their role in dissociative attachment and detachment processes





#### **Outline**

- The 1D particle-in-cell/Monte Carlo collision simulation
- The oxygen discharge
- Capacitively Coupled Oxygen Discharge at 13.56 MHz
  - Pressure dependence including  $O_2(a^1\Delta_g)$
  - The effect of including secondary electron emission
  - $\blacksquare$  The effect of including both  $O_2(a^1\Delta_g)$  and  $O_2(b^1\Sigma_g)$
- Summary





## The 1D particle-in-cell/Monte Carlo collision simulation





### The oopd1 1d-3v PIC/MCC code

- We use the oopd1 (objective oriented plasma device for one dimension) code to simulate the discharge
- The oopd1 code was originally developed at the Plasma Theory and Simulation Group at UC Berkeley
- It has 1 dimension in space and 3 velocity components for particles (1d-3v)
- The oopd1 code is supposed to replace the widely used xpdx1 series (xpdp1, xpdc1 and xpds1)
- It is developed to simulate various types of plasmas, including processing discharges, accelerators and beams
  - Modular structure
  - Includes relativistic kinematics
  - Particles can have different weights





## The oxygen discharge





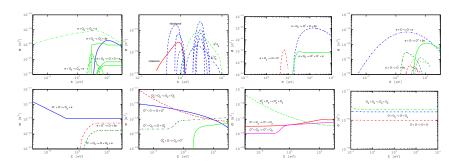
### The oxygen discharge

- We consider a discharge that consists of:
  - electrons
  - the ground state oxygen molecule  $O_2(X^3\Sigma_g^-)$
  - the metastable oxygen molecule  $O_2(a^1_1\Delta_g)$
  - the metastable oxygen molecule  $O_2(b^1\Sigma_g)$
  - the ground state oxygen atom O(<sup>3</sup>P)
  - the metastable oxygen atom O(¹D)
  - the negative oxygen ion O<sup>-</sup>
  - the positive oxygen ions O<sup>+</sup> and O<sup>+</sup><sub>2</sub>
- We apply a global model<sup>1</sup> beforehand to calculate the partial pressure of the various neutrals
- In most PIC/MCC simulations of oxygen discharges to date only O<sub>2</sub><sup>+</sup>, O<sup>-</sup> and electrons have been tracked

<sup>1</sup> Thorsteinsson and Gudmundsson, *Plasma Sources Sci. Technol.*, **19** 055008 (2010)



#### The oxygen discharge



■ The reaction set for the oxygen is comprehensive and for this study includes up to 67 reactions

Gudmundsson et al., Plasma Sources Sci. Technol., 22 035011 (2013), 24 035016 (2015) and 25 055002 (2016)





B. 1. 1. Capacitively Coupled Oxygen Discharge at 13.56 MHz – pressure dependence – including  $O_2(a^1\Delta_a)$ 





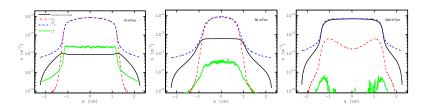
We apply a voltage source with a single frequency

$$V(t) = V_{\rm rf} \sin(2\pi f t)$$

- The electrodes are circular with a diameter of 14.36 cm
- The gap between the electrodes is 4.5 cm
- We set  $V_{\rm rf}$  = 222 V and f = 13.56 MHz
- The neutrals ( $O_2$  and O and the metastables) are treated as background gas at  $T_g$  = 300 K with a Maxwellian distribution
- If the kinetic energy of the neutrals reaches a certain threshold they are tracked
- The dissociation fraction and the metastable fraction is found using a global model
- The pressure is varied from 10 500 mTorr

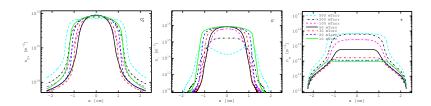






- For a parallel plate capacitively coupled oxygen discharge at 50 mTorr with with a gap separation of 4.5 cm by a 222 V voltage source at 13.56 MHz
  - O<sub>2</sub><sup>+</sup>-ion density profile
  - O<sup>+</sup>-ion density profile
  - O<sup>-</sup>-ion density profile
  - electron density profile



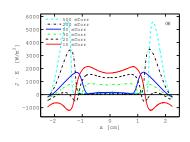


- The sheath width decreases as the pressure is decreased in the pressure range from 50 mTorr to 10 mTorr
- The sheath widths are largest at 50 mTorr
- As the pressure is increased from 50 mTorr up to 500 mTorr the sheath width decreases
- This agrees with what has been observed experimentally in the pressure range 40 375 mTorr

Mutsukura et al. (1990) JAP 68 2657 and van Roosmalen et al. (1985) JAP 58 653



- The electron heating profile J<sub>e</sub> · E
- In the pressure range 50 500 mTorr the electron heating occurs almost solely in the sheath region
- As the pressure is decreased the Ohmic heating contribution in the plasma bulk increases and sheath heating decreases

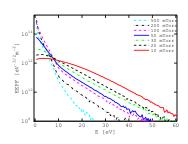


Gudmundsson and Ventéiou (2015) JAP 118 153302





- At low pressure the EEPF is convex, the population of low energy electrons is relatively low
- As the pressure is increased the number of low energy electrons increases and the number of higher energy electrons (> 10 eV) decreases
- Thus the EEPF develops a concave shape or becomes bi-Maxwellian as the pressure is increased



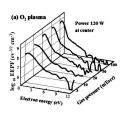
Gudmundsson and Ventéjou (2015) JAP 118 153302



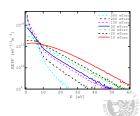




- Our results agree with the measurements of Lee et al.
   (2010) which explored experimentally the evolution of the EEPF with pressure in a capacitively coupled oxygen discharge in the pressure range 3 100 mTorr
- They find that the EEPF became more distinctly bi-Maxwellian and the density of low energy electrons increases as the gas pressure is increased

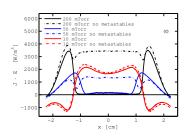


Lee et al. (2010) PRE 81 046402





- At 10 mTorr excluding the metastable states O<sub>2</sub>(a<sup>1</sup>Δ<sub>g</sub>) and O(<sup>1</sup>D) in the simulation has very small influence on the heating mechanism
- At 50 mTorr the metastable states, in particular O<sub>2</sub>(a<sup>1</sup>Δ<sub>g</sub>), have a significant influence on the heating mechanism
- The role of the metastables is even more significant at 200 mTorr



Gudmundsson and Ventéjou (2015) JAP **118** 153302 Gudmundsson and Lieberman (2015) PSST **24** 035016

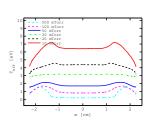




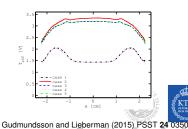


- The effective electron temperature drops as the pressure is increased
- When the metastable singlet oxygen molecule  $O_2(a^1\Delta_g)$  is added to the discharge model the effective electron temperature drops, in particular in the electronegative core due to detachment by the metastable  $O_2(a^1\Delta_g)$  molecule

$$O^- + O_2(a^1 \Delta_a) \rightarrow products$$



Gudmundsson and Ventéjou (2015) JAP 118 153302



B. 1. 2. Capacitively Coupled Oxygen Discharge at 13.56 MHz – pressure dependence – including  $O_2(\mathbf{a}^1\Delta_g)$ ,  $O_2(\mathbf{b}^1\Sigma_g)$  and  $\gamma_{\rm see}(E)$ 



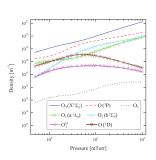


■ It has been known for decades that the metastable oxygen molecule  $O_2(b^1\Sigma_g)$  plays an important role in the oxygen discharge

Thompson (1961) Proc. Royal Soc. A 262(1311) 519

- Recent global model study indicates there is a significant density of O<sub>2</sub>(b<sup>1</sup>∑<sub>g</sub>) in the oxygen discharge
- The  $O_2(b^1\Sigma_g)$  is mainly created through

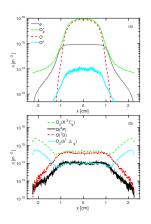
$$O_2(X^3\Sigma_g^-) + O(^1D) \longrightarrow O_2(b^1\Sigma_g) + O(^3P)$$

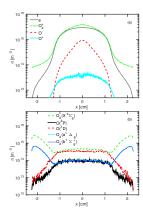


Toneli et al., J. Phys. D, 48 325202 (2015)





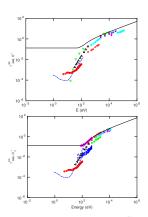


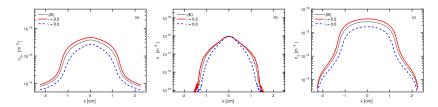


Hannesdottir and Gudmundsson, PSST, **25** 055002 (2016)

■ The density profiles of charged particles and fast neutrals comparing including  $\gamma_{\text{see}}(E)$  and  $O_2(a^1\Delta_g)$  (left) and  $\gamma_{\text{see}}(E)$ ,  $O_2(a^1\Delta_g)$  and  $O_2(b^1\Sigma_g)$  (right) at 50 mTorr

- We have compiled experimental data from the literature on secondary electron emission yields for the species O<sub>2</sub><sup>+</sup>, O<sup>+</sup>, O<sub>2</sub> and O bombarding various metals and substances
- A fit was made through the available experimental data



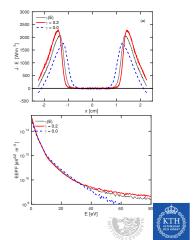


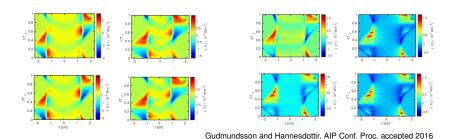
- The  $O_2^+$ ,  $O^-$  and electron density profiles for  $\gamma_{\text{see}} = 0.0$ ,  $\gamma_{\text{see}} = 0.2$ , and energy dependent secondary electron emission yield  $\gamma_{\text{see}}(E)$
- The electron density increases with increased secondary electron emission yield





- Adding secondary electron emission yield
  - increases the electron heating rate in the sheath region
  - the sheath region becomes narrower

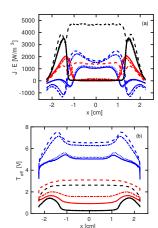




- The spatio-temporal electron heating at 10 mTorr (left) and 50 mTorr (right)
- The four cases explored are:
  - (a) detachment neither by  $O_2(a^1\Delta_g)$  nor  $O_2(b^1\Sigma_g^+)$
  - (b) only detachment by  $O_2(b^1\Sigma_g^+)$  included
  - (c) only detachment by  $O_2(a^1\Delta_g)$  included
  - $\blacksquare$  (d) both detachment by  $O_2(a^1\Delta_g)$  and  $O_2(b^1\Sigma_g^+)$  included

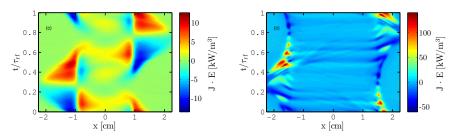


- The number of cold electrons increases as  $O_2(b^1\Sigma_g)$  is added to the discharge model
- The electron heating in the bulk drops to zero at the higher pressures
- The effective electron temperature profile changes significantly when detachment by singlet metastables is added to the reaction set
- 10 mTorr, 50 mTorr and 200 mTorr





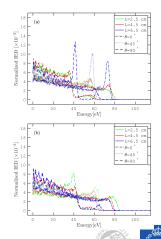




■ The spatio-temporal electron heating at 10 mTorr with a gap separation of 4.5 cm driven by a 222 V voltage source at 13.56 MHz (left) and 27.12 MHz (right)

# Capacitively Coupled Oxygen Discharge Dual Frequency at 13.56 MHz + 27.12 MHz

- The ion energy distribution (IED)
- A dual frequency (13.56 MHz + 27.12 MHz) parallel plate capacitively coupled oxygen discharge at 75 mTorr
  - (a) Detachment by O<sub>2</sub>(a<sup>1</sup>Δ<sub>g</sub>) and O<sub>2</sub>(b<sup>1</sup>Σ<sub>g</sub>) included
  - (b) Detachment by O<sub>2</sub>(a<sup>1</sup>Δ<sub>g</sub>) and O<sub>2</sub>(b<sup>1</sup>Σ<sub>g</sub>) excluded
- For a larger discharge gap (*L* = 6.5 cm), the peak in the IED is much more apparent in the case where the full reaction set is used in the discharge model



Comparison to experimental findings:

$$\gamma_{\text{see}} = 0.0,$$
  
4.4 %  $O_2(a^1 \Delta_g)$ 

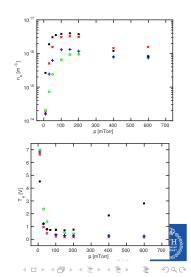
+ 
$$\gamma_{\text{see}} = 0.0$$
,  
4.4 %  $O_2(a^1 \Delta_g)$  and 4.4 %  $O_2(b^1 \Sigma_g)$ 

$$\mathbf{x} \ \gamma_{\text{see}} = \gamma_{\text{see}}(E),$$
  
4.4 %  $O_2(\mathbf{a}^1 \Delta_g)$  and 4.4 %  $O_2(\mathbf{b}^1 \Sigma_g)$ 

Experimental findings by Kechkar

(S. Kechkar, Ph.D. Thesis, Dublin City University, January 2015)

Hannesdottir and Gudmundsson (2016) PSST 25 055002



#### **Summary**

- We demonstrated particle-in-cell/Monte Carlo collision simulation of a capcacitively coupled disharge
- In an oxygen discharge at low pressure the EEPF is convex and develops a concave shape or becomes bi-Maxwellian as the pressure is increased
- These results contradict what is commonly found for the capacitively coupled argon discharge where the EEPF evolves from being concave at low pressure to being convex at high pressure
- Including the detachment processes by the singlet metastable states has a strong influence on the effective electron temperature and electronegativity in the oxygen discharge



#### Acknowledgements

#### The slides can be downloaded at

http://langmuir.raunvis.hi.is/~tumi/ranns.html
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- Bruno Ventéjou (LPGP, Université Paris-Su, Orsay, France)

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- Dr. Emi Kawamura (UC Berkeley)

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